

Final deadline for papers IWGO 2024 - Berlin
5th International Workshop on Gallium Oxide and Related Materials
26-31 May, 2024 Berlin - Germany



**Abstract submission
by 17. December 2023**

The International Workshop on Gallium Oxide and Related Materials (IWGO) is the premier international forum for Ga_2O_3 and related materials. IWGO covers new developments in materials, physics and technology related to oxides. The workshop aims to bring together scientists and engineers working on all aspects of materials and device technology. It will be held in person to enable lively discussions and new contacts. Taking place bi-annually, IWGO is highly up-to-date.

Scientific Program

- Bulk growth
- Epitaxial thin film growth
- Characterization of structural, electronic, and optical properties
- Theory, modeling and simulation
- Electronic and photonic devices
- Material and device processing, and fabrication techniques



For more information
and sponsorship
opportunities see
details below:

iwgo2024@pdi-berlin.de

<https://grafox2022.pdi-berlin.de/iwgo-2024/>

Conference co-Chairs

Oliver Bierwagen - Germany and **Martin Albrecht** - Germany

Technical Program Committee

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Piero Mazzolini , Italy	Hongping Zhao , USA
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Confirmed Invited Speakers

Bulk Growth:

Zbigniew Galazka, Institute of Crystal Growth, DE
Akito Kuramata, Novel Crystal Technology Inc., JP

Epitaxy:

Elaheh Ahmadi, University of California, USA
Roberto Fornari, University of Parma, IT
Riena Jinno, University of Tokyo, JP
Yoshiano Kumagai, Tokyo University of Agriculture and Technology, JP
Darrell Schlom, Cornell University, USA

Characterization:

Andrej Kuznetsov, University of Oslo, NOR
Matthew McCluskey, Washington State University, USA

Theory:

Emmanouil Kioupakis, University of Michigan, USA
Laura Ratcliff, University of Bristol, UK
Uttam Singiseti, University at Buffalo, USA

Device and Processing:

Kornelius Tetzner, Ferdinand Braun Institute, DE
Jiandong Ye, Nanjing University, CN
Esmat Farzana, Iowa State University, USA
Masataka Higashiwaki, Osaka Metropolitan University, JP

